

Resource Summary Report

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Horiba: CM-200A/210A Hydrofluoric Acid Monitor

RRID:SCR_020031

Type: Tool

Proper Citation

Horiba: CM-200A/210A Hydrofluoric Acid Monitor (RRID:SCR_020031)

Resource Information

URL: https://www.horiba.com/en_en/products/detail/action/show/Product/cm-200a210a-712/

Proper Citation: Horiba: CM-200A/210A Hydrofluoric Acid Monitor (RRID:SCR_020031)

Description: CM 200A 210A hydrofluoric acid monitors have been developed specifically to meet stringent demands of semiconductor manufacturing. CM 200A 210A provides real time read out of hydrofluoric acid concentration by measuring electric conductivity of sample solution. These superior units offer high repeatability even at low concentrations. CM 200A 210A can be used for variety of purposes ranging from monitoring etched wafer cleaning processes to any other industrial application of hydrofluoric acid.

Resource Type: instrument resource

Keywords: Horiba, Hydrofuloric Acid Monitor, Instrument Equipment, USEDit,

Availability: Commercially available

Resource Name: Horiba: CM-200A/210A Hydrofluoric Acid Monitor

Resource ID: SCR_020031

Alternate IDs: Model_Number_CMA-200A/210A

Record Creation Time: 20220129T080348+0000

Record Last Update: 20260801T190637+0000

Ratings and Alerts

No rating or validation information has been found for Horiba: CM-200A/210A Hydrofluoric Acid Monitor.

No alerts have been found for Horiba: CM-200A/210A Hydrofluoric Acid Monitor.

Data and Source Information

Source: [SciCrunch Registry](#)

Usage and Citation Metrics

We have not found any literature mentions for this resource.